

## METHOD FOR LATERAL TRIMMING OF SPACERS

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### ABSTRACT

Spacer etch trim techniques are provided. The method controllably trims a multi-film stack spacer utilizing a self-limiting etch technique. The method may use a dry etch etcher with low bias power. The dry etch process may also use other modified parameters, such as gas flows and various pressures.

E D O C U M E N T S O F R E C A R D